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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/755,826	01/04/2001	Charles W. Pearce	PEARCE 26	5388

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EXAMINER

CHEN, JACK S J

ART UNIT PAPER NUMBER

2813

DATE MAILED: 09/24/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No. 09/755,826	Applicant(s) PEARCE, CHARLES W.	
	Examiner Jack Chen	Art Unit 2813	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 08 July 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-20 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-20 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☒ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- | | |
|--|---|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) Paper No(s). _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____ | 6) <input type="checkbox"/> Other: |

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DETAILED ACTION

1. In response to the communications dated July 8, 2003, claims 1-20 are active in this application.

Specification

2. The amendment filed July 8, 2003 is objected to under 35 U.S.C. 132 because it introduces new matter into the disclosure. 35 U.S.C. 132 states that no amendment shall introduce new matter into the disclosure of the invention. The added material which is not supported by the original disclosure is as follows: Re claim 1 and 11, the term "only" is not supported by the original specification.

Applicant is required to cancel the new matter in the reply to this Office Action.

Claim Rejections - 35 USC § 112

3. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

4. Claims 1 and 11 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession

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of the claimed invention. Re claims 1 and 11, the term "only" is not supported by the original specification.

5. Claims 1 and 11 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. See above.

Claim Rejections - 35 USC § 102

6. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in-

(1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or

(2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).

7. Claims 1-3, 5, 6, 8, 10, 11-13, 15, 16, 18, 20 are rejected under 35 U.S.C. 102(e) as being anticipated by Akaishi et al., U.S./6,255,154 B1.

Akaishi et al. discloses a method for forming a semiconductor device, which comprises fabricating laterally diffused metal oxide semiconductor (LDMOS) transistors (fig. 1, col. 2, lines

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34-43; col. 6, lines 32-38), including forming lightly doped source/drain region 22A with *only* a first dopant (in this case, the dopant only having N-type conductivities and the only dopant is the N-type dopant), the lightly doped source/drain region located between first and second isolation structures 9 (fig. 1); and creating a gate 7A over the lightly doped source/drain region (fig. 1); depositing interlevel dielectric layers 13 (figs. 11A-11B, col. 6, lines 46-50) over the LDMOS transistors; and creating interconnect structures 10/11 (figs. 11A-11B, col. 6, lines 46-50) in the interlevel dielectric layers and interconnecting the LDMOS transistors to form an operative-integrated circuit, see figs. 1-11B, cols. 1-8.

Re claims 2 and 12, wherein forming includes forming a lightly doped source/drain region with a first N-type dopant (fig. 2).

Re claim 3 and 13, wherein the first N-type dopant has an implant dose ranging from about $1\text{E}12$ to about $1\text{E}13\text{cm}^{-2}$ (fig. 2).

Re claims 5 and 15, further including diffusing a second dopant at least partially across the lightly doped source/drain region and under the gate to form a first portion of a channel 8 (figs. 1 and 6).

Re claims 6 and 16, wherein diffusing the second dopant includes diffusing a second p-type dopant having an implant dose ranging from about $1\text{E}13$ to about $1\text{E}14\text{cm}^{-2}$ (fig. 6).

Re claims 8 and 18, further including placing a heavy concentration of the first dopant in a region adjacent a source side of the gate, and in the lightly doped source/drain region adjacent a drain side of the gate (fig. 7).

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Re claims 10 and 20, wherein placing includes placing an implant dose of the first dopant ranging from about $1E15$ to about $1E16\text{cm}^{-2}$ (fig. 7).

Claim Rejections - 35 USC § 103

8. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

9. Claims 4, 7, 9, 14, 17, and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Akaishi et al., U.S./6,255,154 B1.

Akaishi et al. disclosed above; however, Akaishi et al. do not explicitly show the dose of first dopant is about $5E12\text{cm}^{-2}$ (Re claims 4 and 14), the dose of the second dopant is about 100 times higher than the dose of the first dopant (Re claims 7 and 17) and placing the heavy concentration of the first dopant at a distance ranging from about 2000 to 3000 nm from the drain side of the gate (Re claims 9 and 19).

Although the exact ranges of the instant claims 4, 14, 7, 17, 9 and 19 are not explicitly stated by Akaishi et al. in the related text, it appears that the general conditions of a claims 4, 14, 7, 17, 9 and 19 are disclosed by Akaishi et al.; therefore, claims 4, 14, 7, 17, 9 and 19 appear to be *Prima facie* obvious over Akaishi et al. Furthermore, it would have been obvious to one

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having ordinary skill in the art at the time the invention was made to modify the method of Akaishi et al. by selecting the suitable dosages for the first and second dopants, and distance from the gate, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. In re Aller, 220 F.2d 454, 456, 105 USPQ 233, 235 (CCPA 1955).

Response to Arguments

10. Applicant's arguments filed 7/8/2003 have been fully considered but they are not persuasive.

Applicant argues that the prior art (Akaishi et al., U.S./6,255,154 B1) fails to show forming gate over a lightly doped source/drain region, the examiner disagrees because region 22A is considered as the LDD region since it provides the same affects (see col. 3, lines 51-61) as applicant's claimed invention, further in regard, region 22A is formed by the same process (i.e., by ion implantation) as applicant's claimed invention and forming the gate over region 22A; moreover, region 5 is considered as drain in general.

Conclusion

11. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack Chen whose telephone number is (703) 308-5838. The examiner can normally be reached on Monday-Friday (alternate Monday off) from 8:30 am to 6:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr., can be reached on (703)308-4940. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9318 for regular communications and 703-872-9319 for After Final communications.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

A handwritten signature in black ink, appearing to read "Jack Chen", with a long horizontal flourish extending to the right.

Jack Chen

Primary Examiner

September 22, 2003